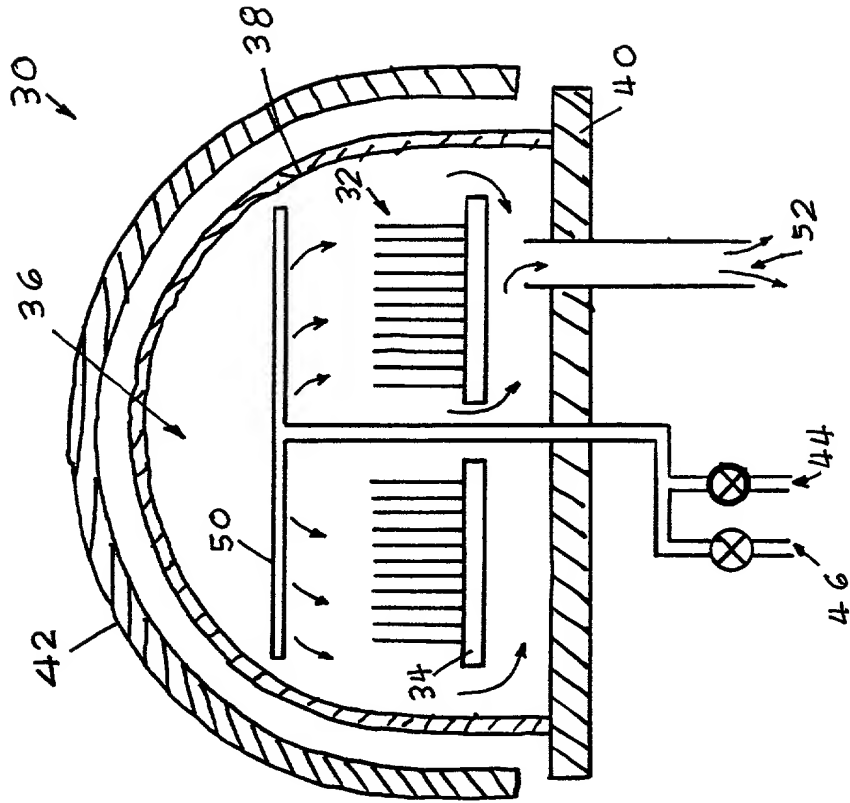


PRIOR ART.



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FIG. 2

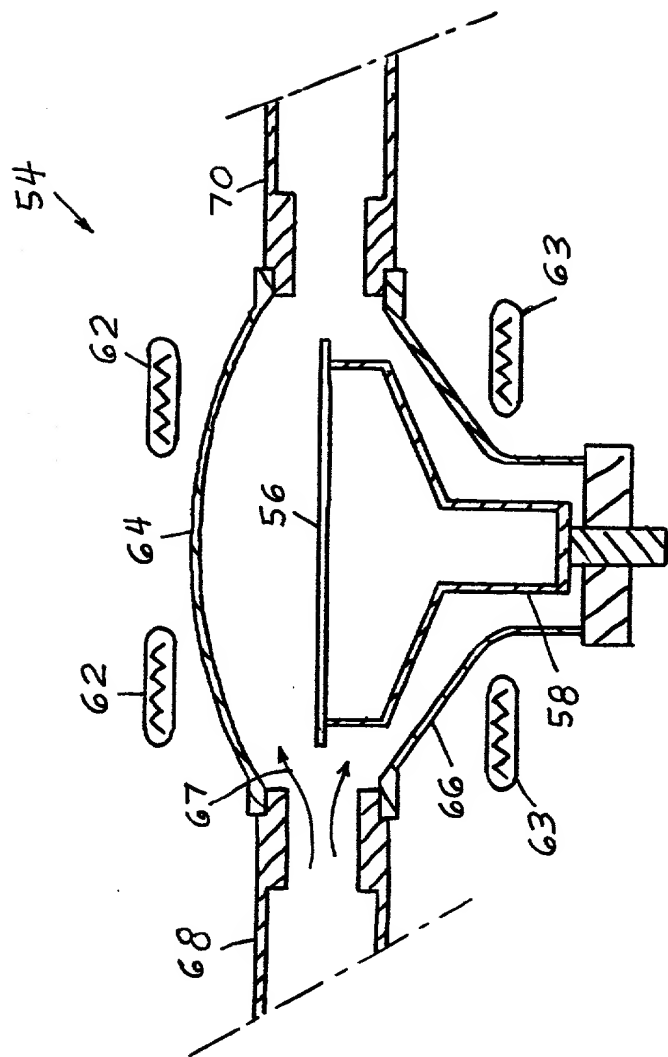


FIG. 3

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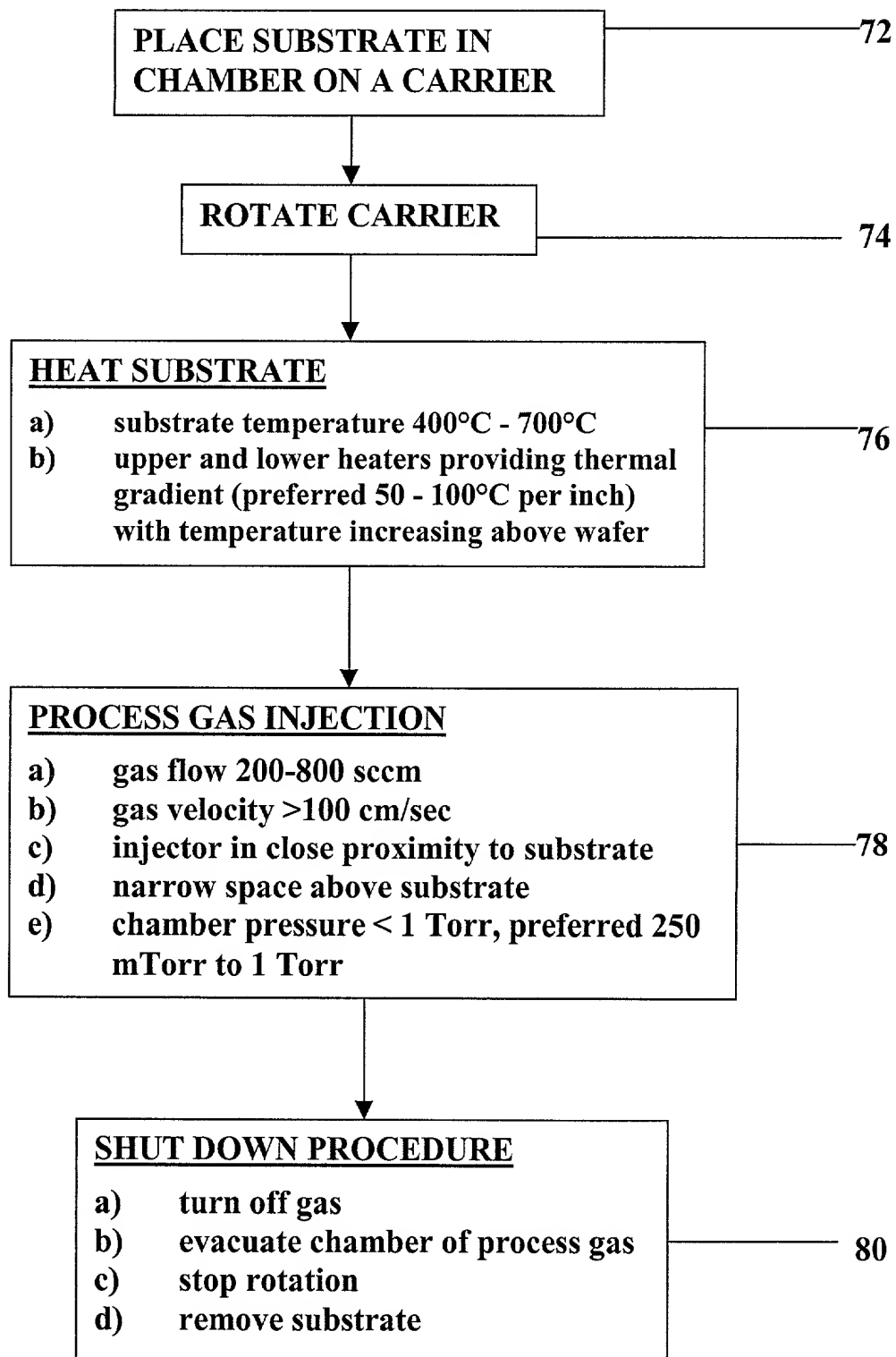
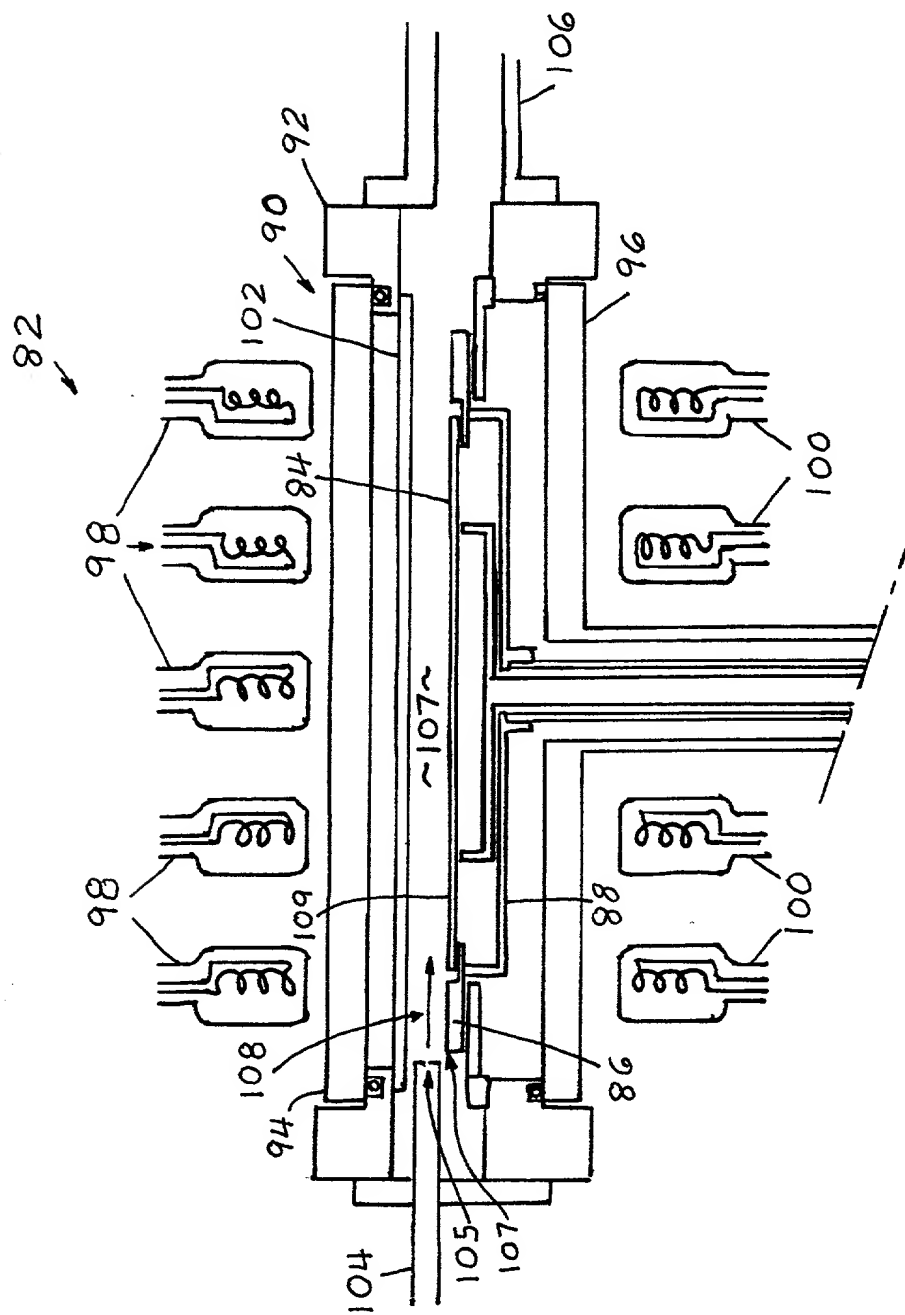


FIG. 4



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Deposition Rate vs Temperature

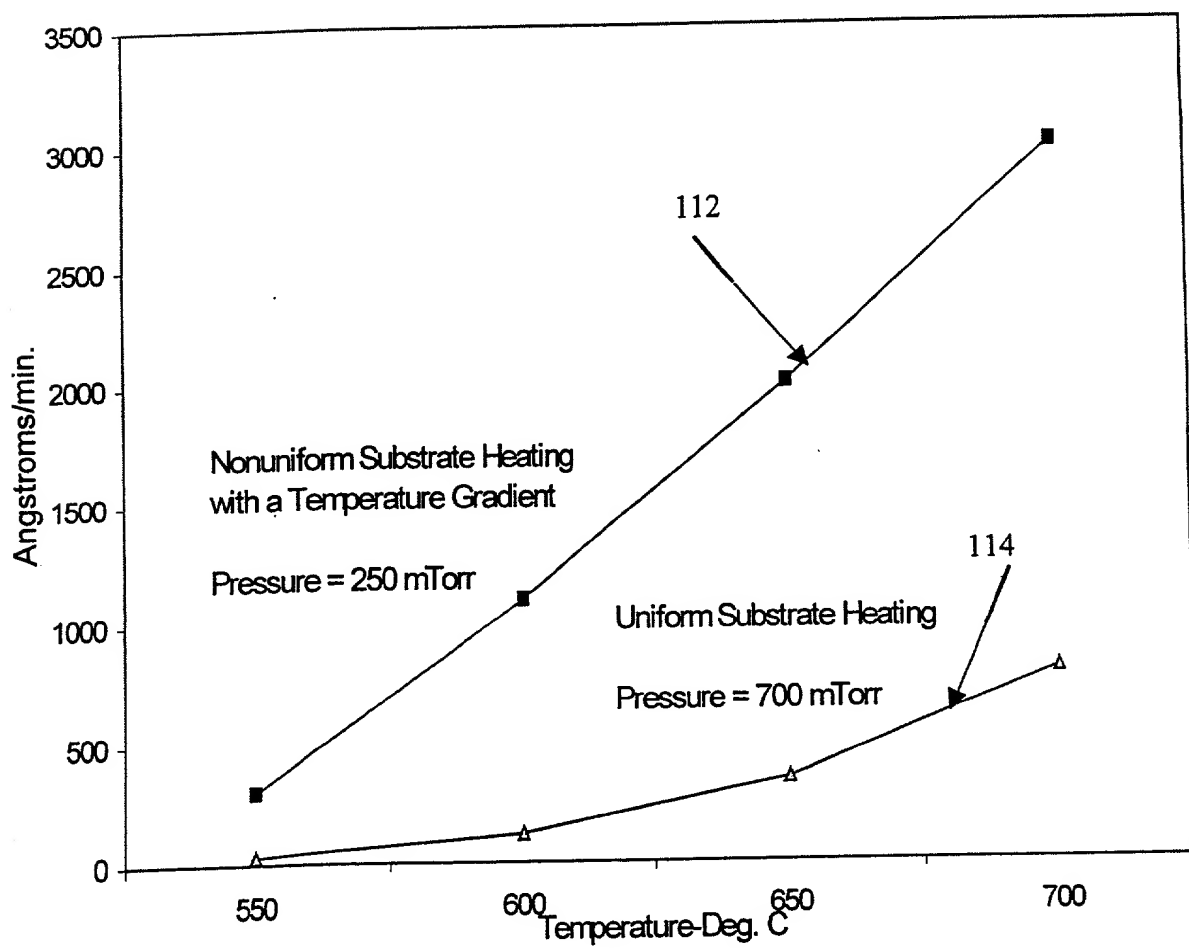


Figure 6

Silicon Deposition Rate vs Silane Flow
with Non-uniform Substrate Heating

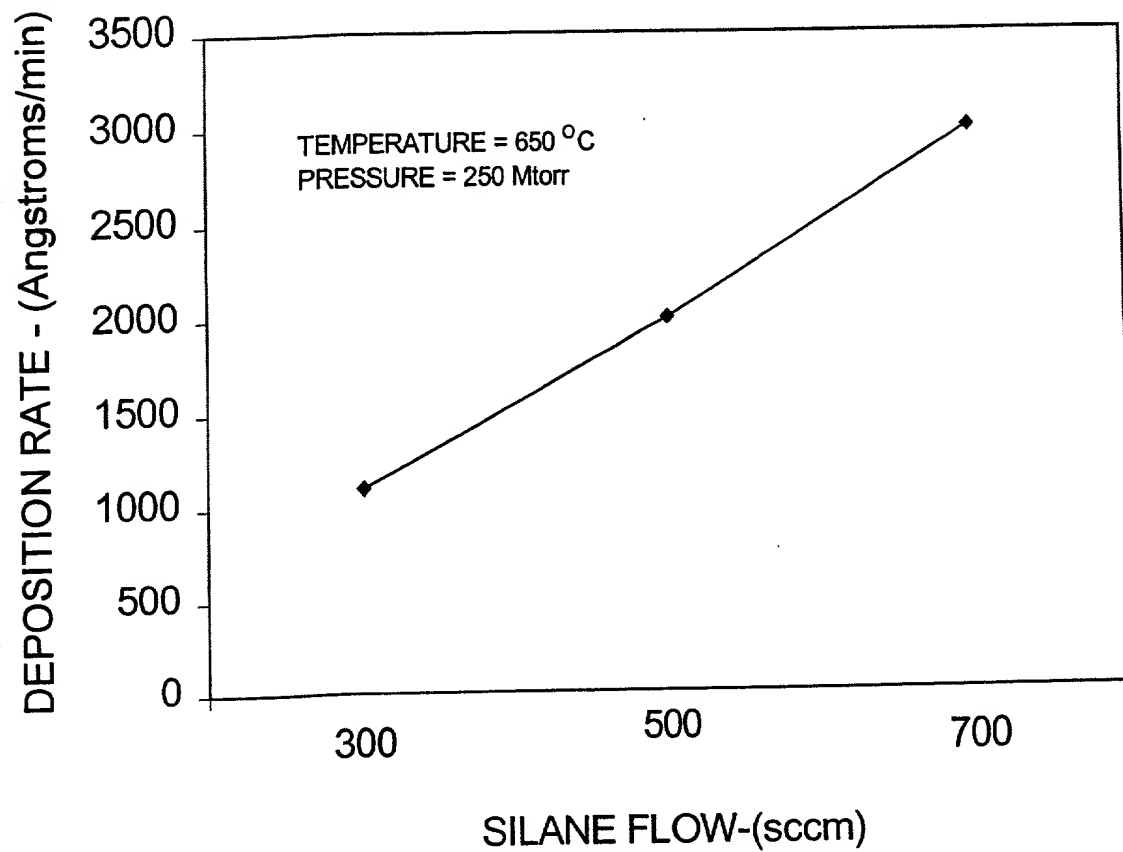


Figure 7

Silicon Nitride Deposition Rate versus Silane Flow

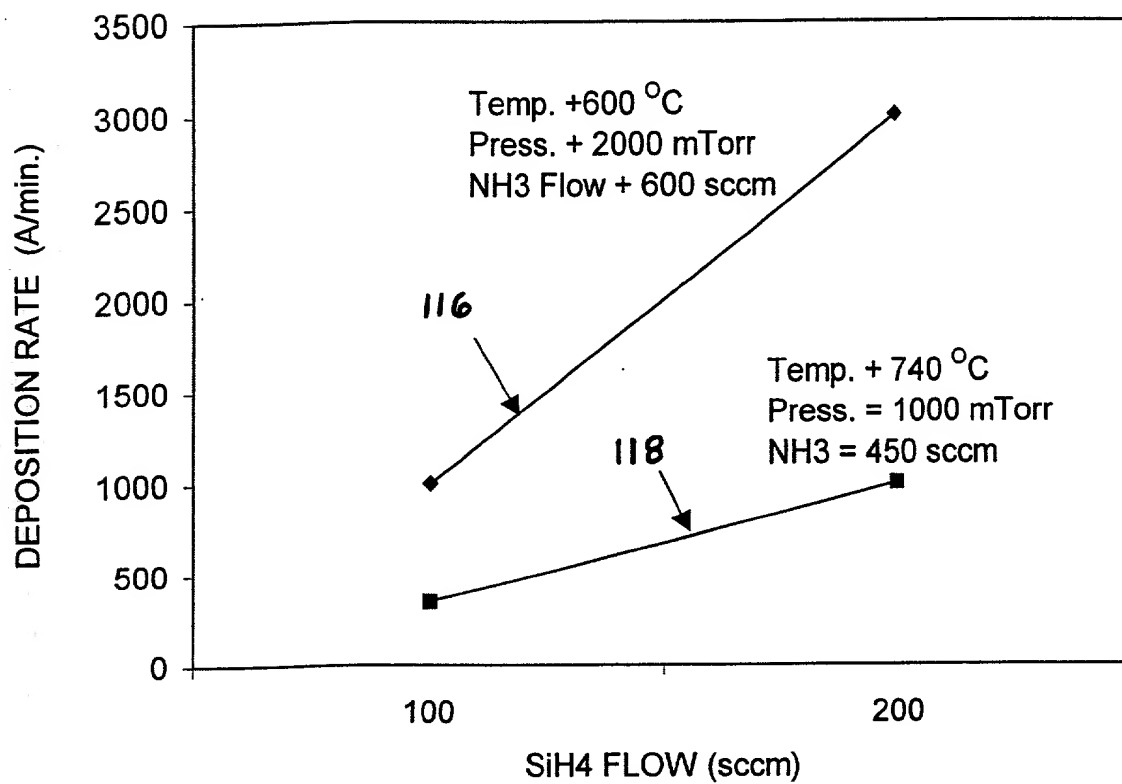


Figure 8

Silicon Nitride Deposition Rate versus Pressure

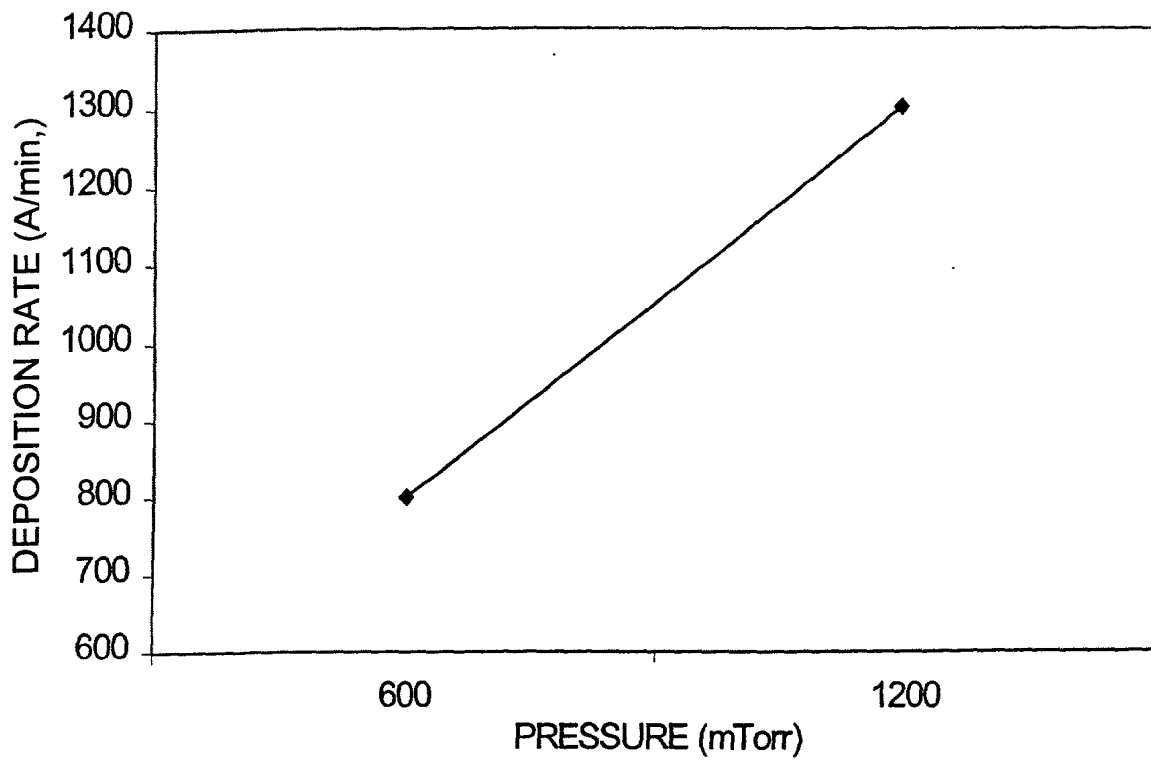


Figure 9